DE LA RECHERCHE À L'INDUSTRIE



Correlations between Tunneling Spectroscopy and SRF cavity perfomances



Thomas Proslier TTC – CERN - 05/02/220

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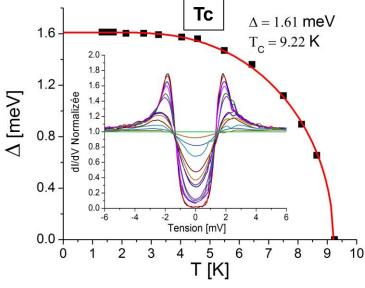
Cornell: D. Hall, M. Liepe (Nb3Sn)

- Point Contact Tunneling spectroscopy
- Bulk Nb treatments
- Nb3Sn/Nb
- Summary and future

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Tunneling spectroscopy: what do we measure and why?

measure $2(\Delta + \Gamma)$ 2,0-0,2 Conductance Normalisée dl/dV 1,5 Courant I [µA] 1,0 0,0 Δ = 1.62 meV Γ = 0.01 meV 0,5 T = 1.34 K Γ/Δ 0.0 -0,2 2 -10 -2 0 6 8 -8 -6 10 Tension [mV]



principle

Nb₂O_{5-_} NbO₂ NbO-NbO_x

Bulk Nb

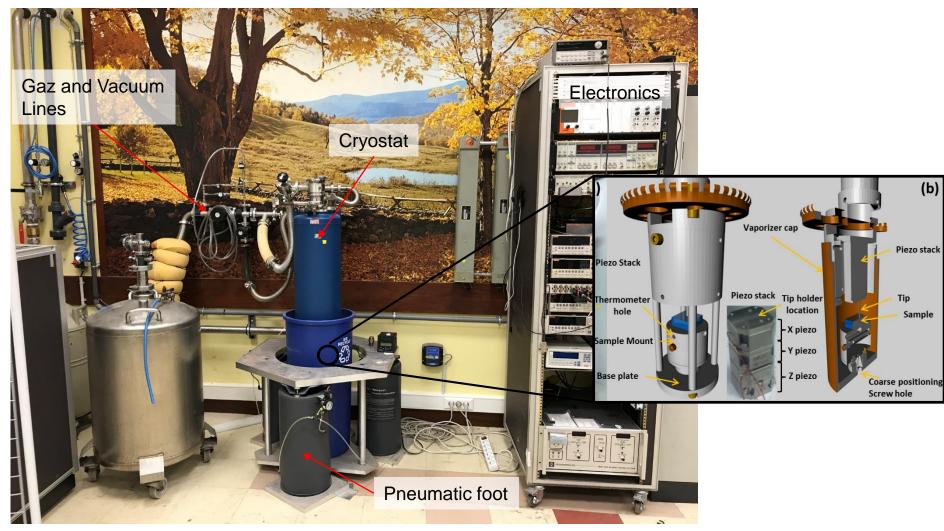
Gold Tip

Measure the fundamental superconducting parameters:

$\Delta,\,T_C,\,H_{C2}$

- Measure non-ideal signature: Γ.
- Shape of the DOS give clues to microscopic origins: *Proximity effect, magnetic impurties, deleterious phases.*
- Direct correlation to SRF cavity performances.
- Cartography.

The Point Contact system at CEA

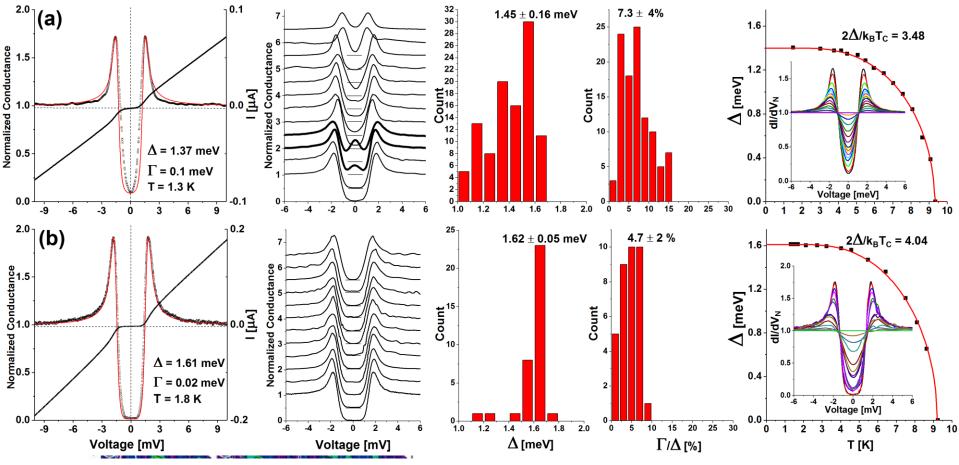


- Temp: 1,4 K
- Magnetic field: 6 T
- Cartography: 10 µm 1 mm
- Sample size: 10x10 mm
- Fast measurements: 100-300 jonctions/5hrs
- Transport (RRR, Tc vs H applied...)
- Hall Effect

Used for Nb/Cu, bulk Nb doping, Nb3Sn, mutlilayers etc...

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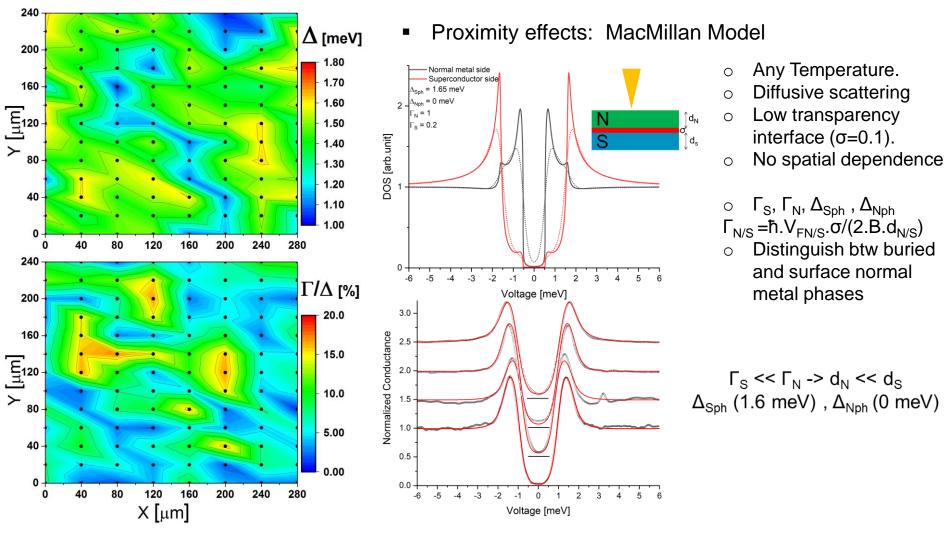
Tunneling spectroscopy: Bulk Nb HFQS



- Hot Spots:
- spread of gap values as low as 1 meV
- Inelastic scattering parameters F
- Zero Bias Peaks

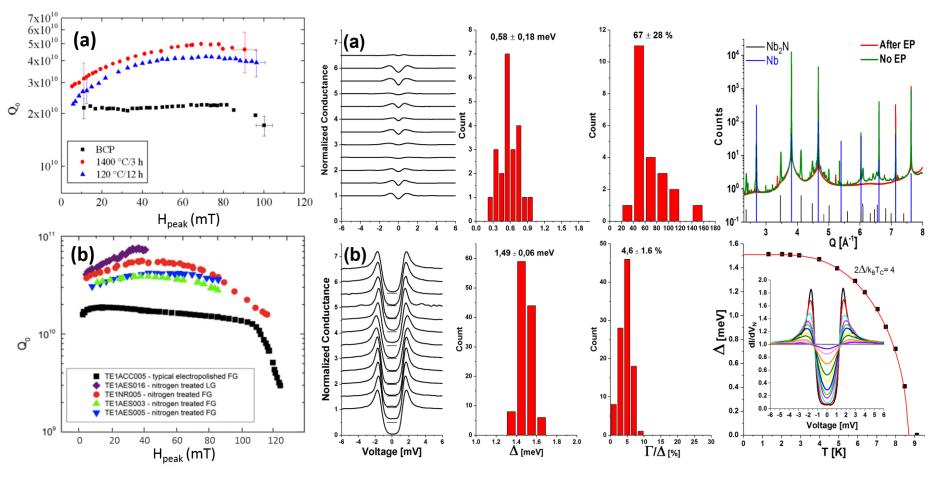
- <u>Cold Spots:</u>
- Narrow gap distibution 1.6 meV
- Lower Inelastic scattering parameters F
- No zero bias peaks

Tunneling spectroscopy: bulk Nb - Why small gaps?



- Presence of normal metal regions: 10 nm < d_N < 15 nm -> reduce the quench field of SRF cavities: H_B ~ Φ₀ / (6 λ_N d_N) Onset at 100 mT -> d_N ≤ 20 nm consistent with PTC.
 Transparent at low fields (Q0) but revealed at « higher » accelerating gradients.
- Candidates: Nb Hydride phases at the surface (XRD at 90 K no sign of NbH_x phases)

Tunneling spectroscopy: Nb Doping: N and Ti

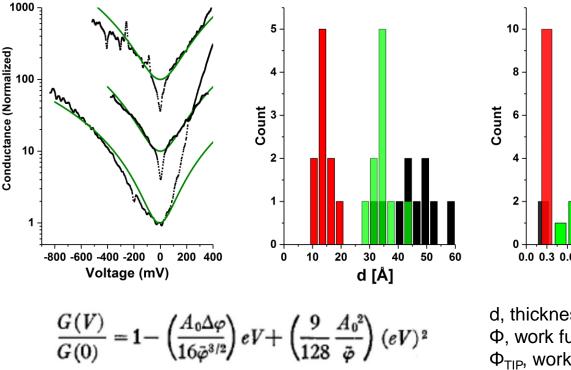


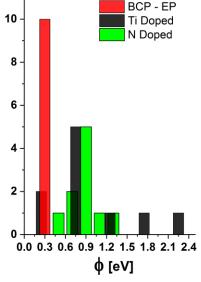
- N / Ti Doping:
- Narrow gap distribution
- Very low Inelastic scattering Γ values
- Near ideal DOS
- No Zero Bias Peaks

- But:
- Gap values a bit lower (1.48 meV) than bulk Nb (1.6 meV)
- Tc (8.7 K) < Bulk Nb Tc (9.2)
- Ratio $2\Delta/kTc = 4$ (similar to this cavity)

Tunneling spectroscopy: Nb

High Bias region



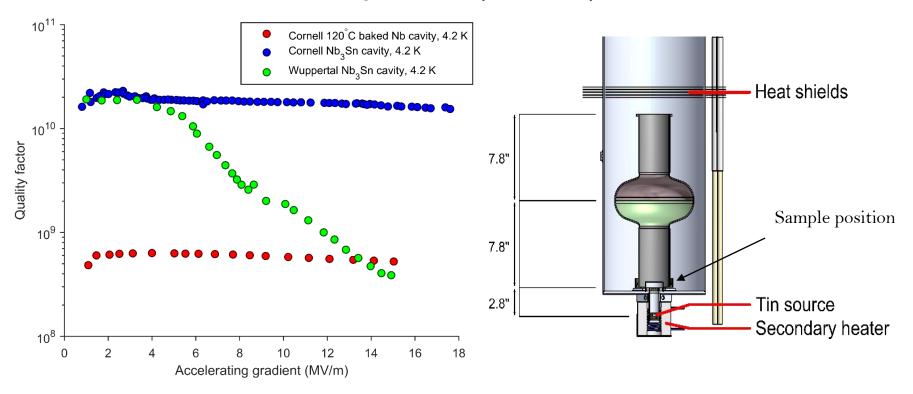


d, thickness of the oxide $\Phi,$ work function of the oxide $\Phi_{\text{TIP}},$ work function of the tip

- Undoped: reduced barrier height and thickness
- Doped (Ti or N): higher barrier height and thickness
 Points towards defects in the oxide mitigated by addition of dopants:
- TLS Hydrogen relationship and ZBP as signature
- Qbits : magnetic impurities, H + O(?) as a source of it
- Low fields measurements

- Point Contact Tunneling spectroscopy
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Nb₃Sn/Nb (Cornell)

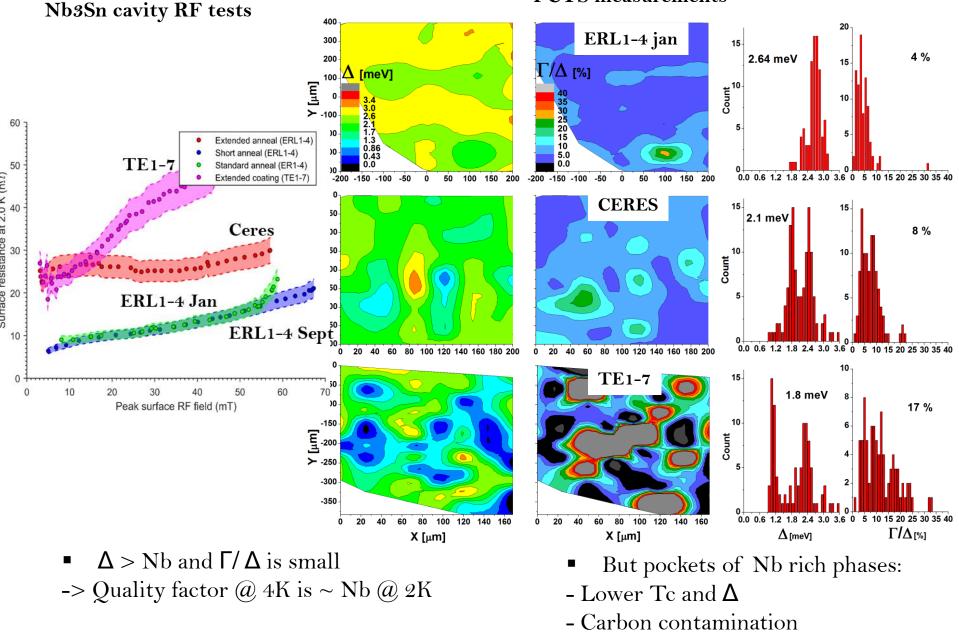


- Wupperthal method: diffusion of Sn in a Nb cavity
- $Nb_3Sn Q_0$ at 4,2K ~ $Nb Q_0$ at 2K
- Moderate increase of Q_0 between 4K to 2K -> Non-BCS
- Q_0 decrease at ~ 6K

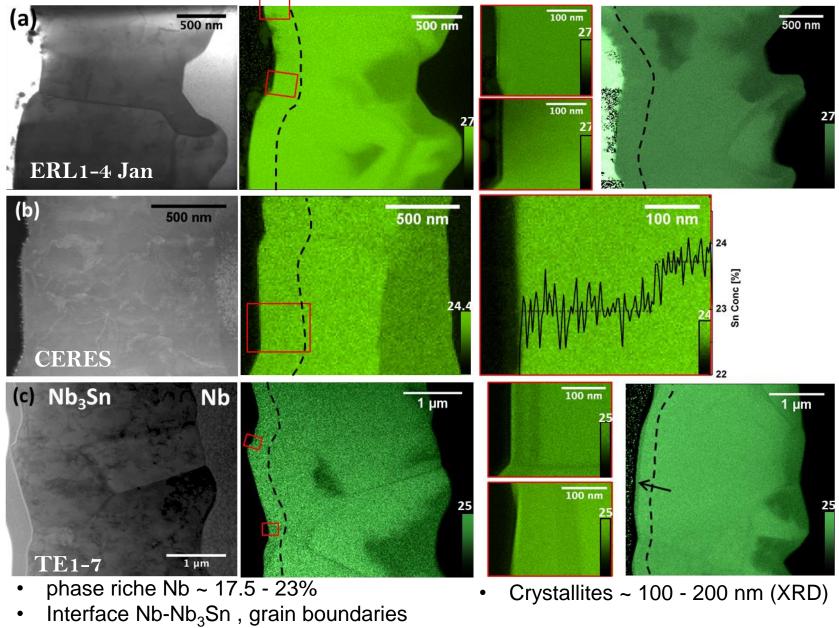
Have we reached the limits of Nb_3Sn ?

Nb₃Sn/Nb (Cornell) - PCT





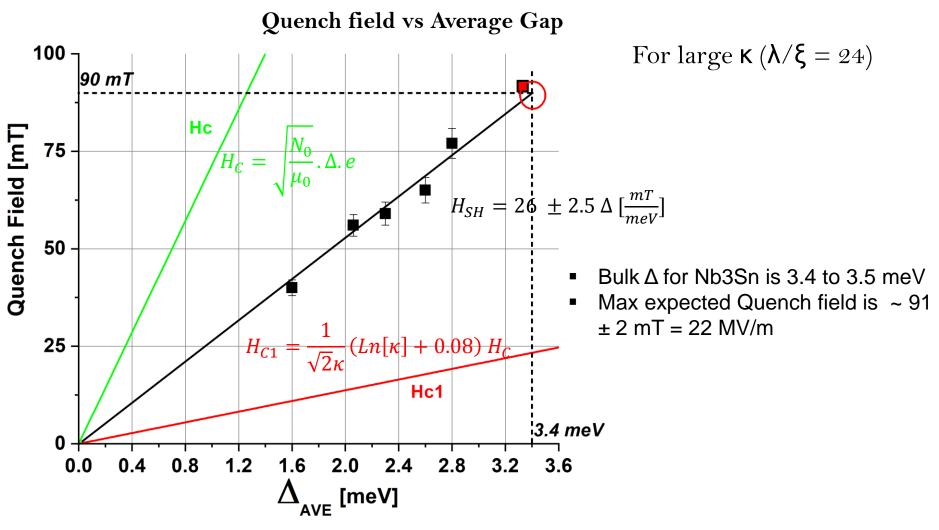
Nb₃Sn/Nb (Cornell) – TEM



Pockets near the surface

IRFU/Service

Nb₃Sn/Nb (Cornell - FNAL) – PCT



- Linear dependence of Emax on the average surface gap (~300x300 μm)
- H_{SH}~3.5 times the H_{C1} but why this gap dependence? Roughness, effective penetration depth?
- > A15 compounds (V₃Si, Nb₃Sn, Nb₃Al...) are good for Q_0 and higher operation temp. (4,2 K)
- > But what about E_{MAX} ? How to increase E_{MAX} ?

- Point Contact Tunneling spectroscopy
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<u>Summary:</u>

- Enable testing surface treatments/heterostructures on coupons prior to cavity tests
- Faster turner over and phase space exploration of growth parameters etc...
- > Measurement of Nb₃Sn sample from FNAL
- Nb3Sn : linear dependence of Emax and the superconducting gap.
- > Nb: à déterminer.

<u>Future</u>:

- Faraday Cage to improve noise (ordered) ~ 3 months.
- Measure of infusion in bulk Nb and Nb3Sn thin films from DESY, Jlab, STFC.
- Bulk Nb: Correlation between inhomogeneous properties and samples measurements
- > Smaller scan areas < 1 μ m.

Thanks you

The END



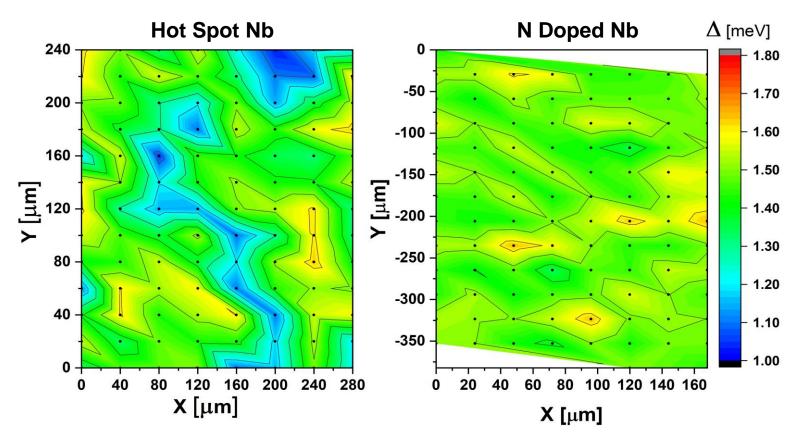
Funding Sources





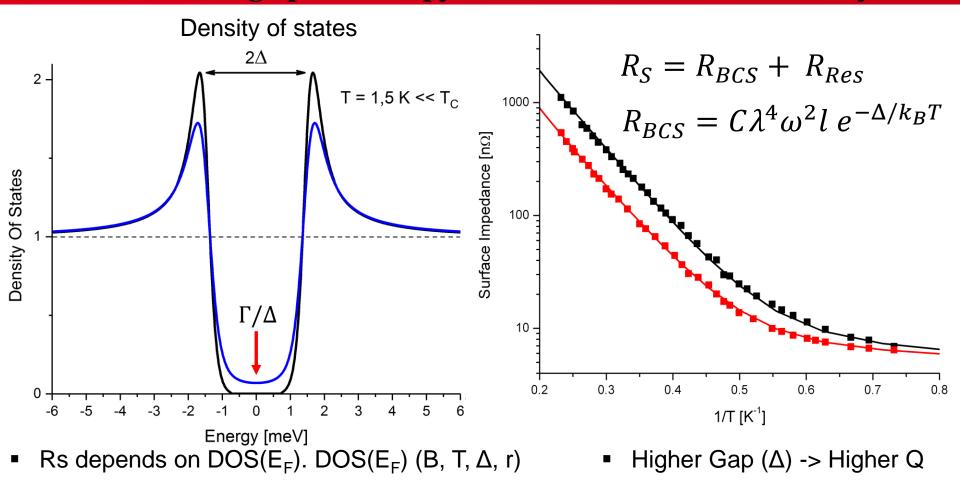


Cartography



- N doping: Homogeneous bulk Nb gap values on the surface
- Hot spot: Regions with low superconducting gap values that can be fitted with normal metal regions on the surface (presumably hydrides)

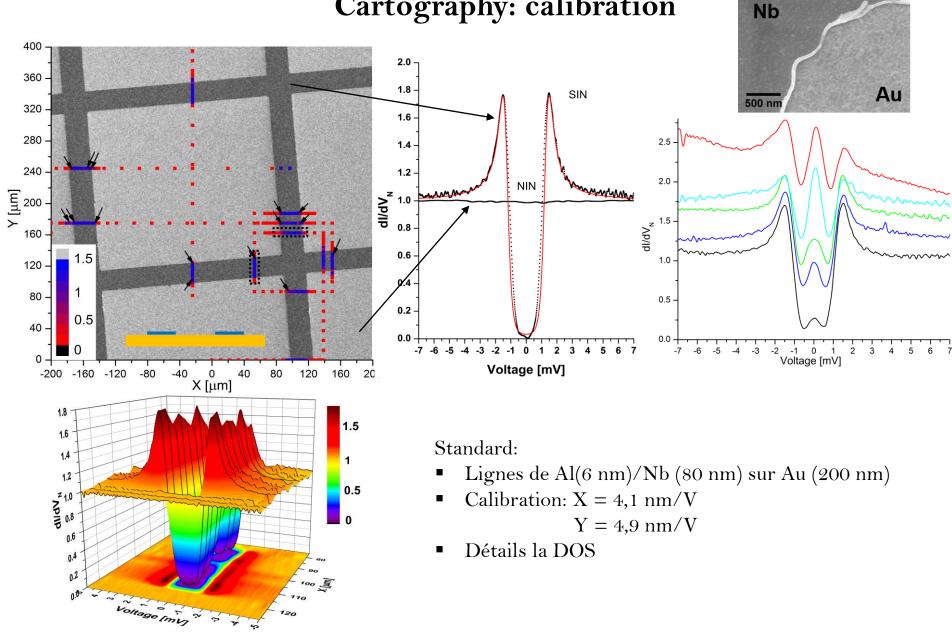
Tunneling spectroscopy: what do we measure and why?



- DOS $(E_F) \neq 0 \rightarrow \text{dissipation} @ T=0 K$
- $DOS(E_F)$ (B, T, Δ , r), $R_S = \langle DOS(E_F) (B, T, \Delta) \rangle_r$
- Saturation mechanisms of the DOS? -> Inelastic scattering (Γ)

IRFU/Service

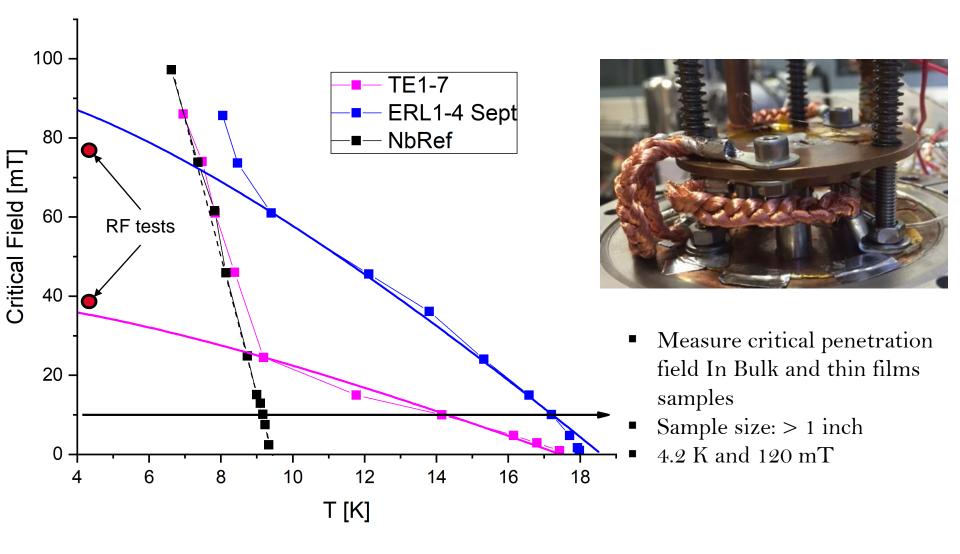
Cartography: calibration



IRFU/Service

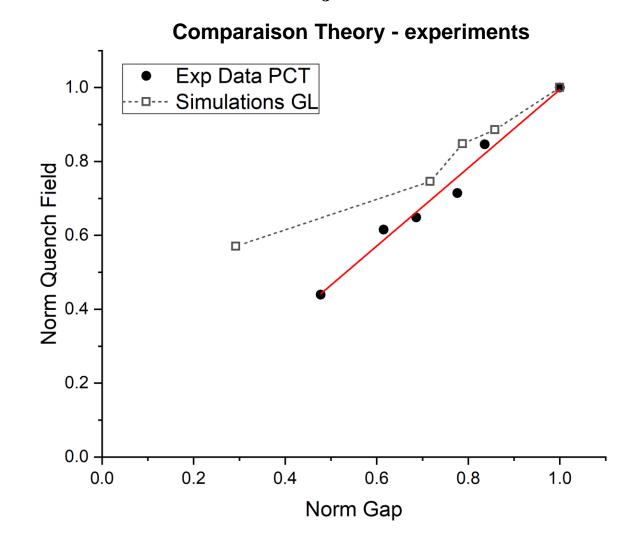
DESY-091219

Nb₃Sn/Nb (Cornell) - Magnetometry



• The critical field measured by Magnetometry correlates with RF tests Quench fields

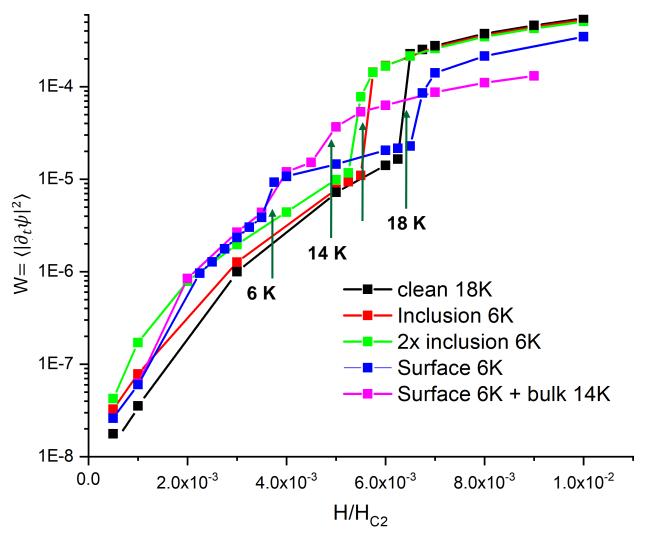
Nb₃Sn/Nb



- Qualitative agreement between GL simul and PCT data
- To be continued

Nb_gSn/Nb - simulation

Case of surface layer Low Tc 6K + lower bulk Tc 14K



Lower bulk Tc also lead to lower penetration field.